

USAGE FEE SCHEDULE FOR ACADEMIC USERS FROM UTA

All hourly fees are per person (student, post-doc). Minimum time unit is 1 hr.

All supplies and consumables are to be provided (subject to the approval of the NanoFab management) by the user except for those provided by NanoFab. Consumables specific to equipment might have to be purchased from NanoFab. A list of consumables provided free of charge and those to be purchased from NanoFab is provided upon request.

<i>Equipment / Service</i>	<i>New User fee</i>	<i>Usage, Assisted Usage, Training (Prior on-site training required) /hr</i>	<i>Maximum per quarter per faculty</i>	<i>Policy for maximum fee</i>
Monthly Access Fee		None		
General Lithography / Patterning	None	\$45	\$900	can be combined with usage of other common equipment in NanoFab towards max. fee of \$1,300/quarter/group.
General Wet Chemistry	None	\$45		
RF / DC Sputtering	None	\$45		
Thermal Evaporation	None	\$45		
PLD / Laser Annealing	None	\$45		
E-Beam Evaporation	None	\$45		
PECVD	None	\$45		
DRIE	None	\$45		
RIE (III-V)	None	\$45		
AFM	None	\$45		
RTA	None	\$45		
Dicing Saw	None	\$45		
E-Beam Writer*	\$450	\$70		
FIB *		\$70		
SEM / EDAX *		\$45	\$900	
Safety Training (required)	None	free	-	-
NanoFab Tours / Usage Assessment	None	free	-	-

INDUSTRIAL USAGE FEE SCHEDULE FOR ATI COMPANIES

All fees are per person (ATI company employee). Minimum time unit is 1 hr.

All supplies and consumables are to be provided (subject to the approval of the NanoFab management) by the user except for those provided by NanoFab. Consumables specific to equipment might have to be purchased from NanoFab. A list of consumables provided free of charge and those to be purchased from NanoFab is provided upon request.

<i>Equipment / Service</i>	<i>Usage, Assisted Usage, Training (Prior on-site training required) /hr</i>	<i>Maximum per quarter per person (ATI company employee)</i>	<i>Policy for maximum fee</i>
Monthly Access Fee	None		
General Lithography / Patterning	\$45	\$4,000	can be combined with usage of other common equipment in NanoFab towards max. fee
General Wet Chemistry	\$45	\$4,000	
RF / DC Sputtering	\$45	\$4,000	
Thermal Evaporation	\$45	\$4,000	
PLD / Laser Annealing	\$45	\$4,000	
E-Beam Evaporation	\$45	\$4,000	
PECVD	\$45	\$4,000	
DRIE	\$45	\$4,000	
RIE (III-V)	\$45	\$4,000	
AFM	\$45	\$4,000	
RTA	\$45	\$4,000	
Dicing Saw	\$45	\$4,000	
E-Beam Write	\$70	None	
FIB	\$70	None	-
SEM / EDAX	\$45	None	-
Safety Training (required)	free	-	-
NanoFab Tours / Usage Assessment	free	-	-

INDUSTRIAL USAGE FEE SCHEDULE for NON-ATI COMPANIES

All fees are per person. Minimum time unit is 1 hr.

All supplies and consumables are to be provided (subject to the approval of the NanoFab management) by the customer except for those provided by NanoFab. Consumables specific to equipment might have to be purchased from NanoFab. A list of consumables provided free of charge and those to be purchased from NanoFab is provided upon request.

<i>Equipment / Service</i>	<i>Set-Up</i>	<i>Usage (Prior on-site training required) /hr</i>	<i>Training /hr</i>	<i>Assisted Usage /hr</i>
Monthly Access Fee	\$400/mo			
General Lithography / Patterning	-	\$100	\$150	\$150
General Wet Chemistry	-	\$100	\$150	\$150
RF / DC Sputtering	-	-	-	\$200
Thermal Evaporation	-	\$100	\$200	\$200
PLD / Laser Annealing	-	-	-	\$300
E-Beam Evaporation	\$100	-	-	\$300
PECVD	\$100	\$200	\$300	\$300
DRIE	\$100	\$200	\$300	\$300
RIE (III-V)	\$100	\$200	\$300	\$300
AFM	-	\$100	\$150	\$150
RTA	-	\$200	\$300	\$300
E-Beam Write	\$100	-	-	\$300
FIB	\$100	-	-	\$300
SEM / EDAX	-	-	-	\$300
Dicing Saw	\$100			\$150
Safety Training (required)	-	free	-	-
NanoFab Tours / Usage Assessment	-	free	-	-

USAGE FEE SCHEDULE FOR NON-UTA ACADEMIC USERS

<i>Equipment / Service</i>	<i>Usage, Assisted Usage, Training (Prior on-site training required) /hr</i>	<i>Maximum per quarter per person (Post-doc, student, faculty)</i>	<i>Policy for maximum fee</i>
Monthly Access Fee	None		
General Lithography / Patterning	\$45	\$4,000	can be combined with usage of other common equipment in NanoFab towards max. fee
General Wet Chemistry	\$45	\$4,000	
RF / DC Sputtering	\$45	\$4,000	
Thermal Evaporation	\$45	\$4,000	
PLD / Laser Annealing	\$45	\$4,000	
E-Beam Evaporation	\$45	\$4,000	
PECVD	\$45	\$4,000	
DRIE	\$45	\$4,000	
RIE (III-V)	\$45	\$4,000	
AFM	\$45	\$4,000	
RTA	\$45	\$4,000	
Dicing Saw	\$45	\$4,000	
E-Beam Write	\$70	None	
FIB	\$70	None	-
SEM / EDAX	\$45	None	-
Safety Training (required)	free	-	-
NanoFab Tours / Usage Assessment	free	-	-